

JAPW



PATENT
Attorney Docket No. 01197.0276-00

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
Hiroshi YAMADA et al.) Group Art Unit: 1795
Application No.: 10/587,315) Examiner: Vaughan II, Juan E.
Filed: July 26, 2006)
For: PHOTOSENSITIVE RESIN) Confirmation No.: 4548
COMPOSITION FOR LASER)
ENGRAVABLE PRINTING)
SUBSTRATE (as amended))

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

SUPPLEMENTAL AMENDMENT

Please amend this application to correct an error in the amendment filed

August 21, 2008:

Amendments to the Claims are reflected in the listing of claims in this paper.

Remarks follow the amendment sections of this paper.